

Day : Monday  
Date: 7/18/2005

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Time: 15:31:48

## Inventor Name Search Result

Your Search was:

Last Name = OMORI

First Name = SHINJI

Application#	Patent#	Status	Date Filed	Title	Inventor Name
<u>11057028</u>	Not Issued	020	02/11/2005	MASK, METHOD OF PRODUCTION OF SAME, AND METHOD OF PRODUCTION OF SEMICONDUCTOR DEVICE	OMORI, SHINJI
<u>10885822</u>	Not Issued	041	07/07/2004	COMPLEMENTARY DIVISION MASK, METHOD OF PRODUCING MASK, AND PROGRAM	OMORI, SHINJI
<u>10848918</u>	Not Issued	030	05/19/2004	METHOD OF GENERATING MASK DISTORTION DATA, EXPOSURE METHOD AND METHOD OF PRODUCING SEMICONDUCTOR DEVICE	OMORI, SHINJI
<u>10843485</u>	Not Issued	083	05/12/2004	MASK, METHOD OF PRODUCING MASK, AND METHOD OF PRODUCING SEMICONDUCTOR DEVICE	OMORI, SHINJI
<u>10843484</u>	Not Issued	030	05/12/2004	MASK, METHOD OF PRODUCING MASK, AND METHOD OF PRODUCING SEMICONDUCTOR DEVICE	OMORI, SHINJI
<u>10834552</u>	Not Issued	030	04/29/2004	MASK, MASK BLANK, AND METHODS OF PRODUCING THESE	OMORI, SHINJI
<u>10689098</u>	Not Issued	018	10/21/2003	MASK, METHOD OF PRODUCING MASK, AND METHOD OF PRODUCING SEMICONDUCTOR DEVICE	OMORI, SHINJI
<u>10534917</u>	Not Issued	019	01/01/0001	EXPOSURE APPARATUS, EXPOSURE METHOD AND SEMICONDUCTOR DEVICE MANUFACTURING METHOD	OMORI, SHINJI
<u>10509230</u>	Not Issued	030	09/24/2004	MASK PATTERN CORRECTION METHOD, SEMICONDUCTOR	OMORI, SHINJI

				DEVICE MANUFACTURING METHOD, MASK MANUFACTURING METHOD AND MASK	
<u>10343701</u>	<u>6787785</u>	150	02/03/2003	MASK AND PRODUCTION METHOD THEREFOR AND PRODUCTION METHOD FOR SEMICONDUCTOR DEVICE	OMORI, SHINJI
<u>08226837</u>	<u>5675363</u>	150	04/13/1994	METHOD AND EQUIPMENT FOR CONTROLLING DISPLAY OF IMAGE DATA ACCORDING TO RANDOM-SCAN SYSTEM	OMORI, SHINJI
<u>06573323</u>	<u>4644582</u>	150	01/24/1984	IMAGE REGISTRATION METHOD	OMORI, SHINJI

Inventor Search Completed: No Records to Display.

Search Another: Inventor

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Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	103	Omori-Shinji.IN.	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/07/18 15:35
L2	16	1 and (mask adj pattern)	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/07/18 15:35
L3	0	2 and (plural adj marks)	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/07/18 15:36
L4	4	2 and (transfer adj function)	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/07/18 15:36
L5	1	"6787785"	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/07/18 15:40
S1	174050	semiconductor and mask	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/07/18 11:53
S2	44	S1 and (plural adj marks)	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/07/18 15:36
S3	13	S2 and (mask adj pattern)	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/07/18 15:35
S4	2	S3 and (position adj data)	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/07/18 11:57
S5	0	S4 and (transfer adj function)	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/07/18 11:57
S7	0	S2 and (transfer adj function)	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/07/18 15:36
S8	1375	S1 and (transfer adj function)	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/07/18 11:57

S9	178	S8 and (mask adj pattern)	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/07/18 11:57
S10	11	S9 and (position adj data)	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/07/18 13:41
S11	3	S10 and (inverse adj function)	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/07/18 13:41
S12	174050	semiconductor and mask	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/07/18 13:40
S13	1375	S12 and (transfer adj function)	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/07/18 13:40
S14	178	S13 and (mask adj pattern)	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/07/18 13:40
S15	11	S14 and (position adj data)	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/07/18 13:40
S17	3	S15 and (inverse adj function)	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/07/18 13:41
S18	156	S14 and surface	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/07/18 13:42
S19	9	S18 and (correct\$3 near4 (mask adj pattern))	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/07/18 14:07
S20	3	("20010049811" "20020000524" "5831272").PN.	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/07/18 14:09
S21	174050	semiconductor and mask	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/07/18 14:08

S22	44	S21 and (plural adj marks)	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/07/18 14:08
S23	13	S22 and (mask adj pattern)	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/07/18 14:09
S24	2	S20 and (mask adj pattern)	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	OR	ON	2005/07/18 14:11